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Fast relaxation of photo-excited carriers in 2D transition metal dichalcogenides

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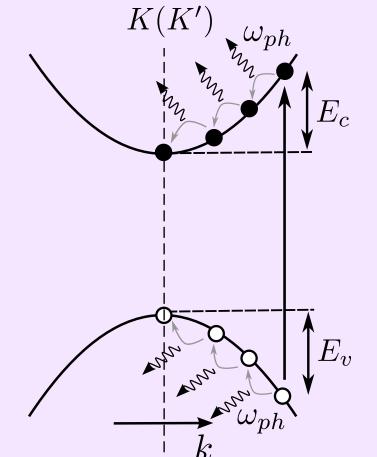
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Introduction

Monolayer transition metal dichalcogenides (TMDCs) denoted by MX₂ consist of a transition metal atom M, covalently bonded to two chalcogen atoms X in the unit cell, and arranged in a hexagonal lattice. These materials possess unique properties [1], including: a direct-band-gap in the visible range at the two degenerate and inequivalent valleys of the Brillouine zone K and K', strong optical absorption, large exciton binding energies, and large spin splitting in the valence and conduction bands, making them ideal for optoelectronics applications [2]. Understanding the process of energy relaxation in these materials, which leads to radiative recombination, is of particular importance for optoelectronics applications.

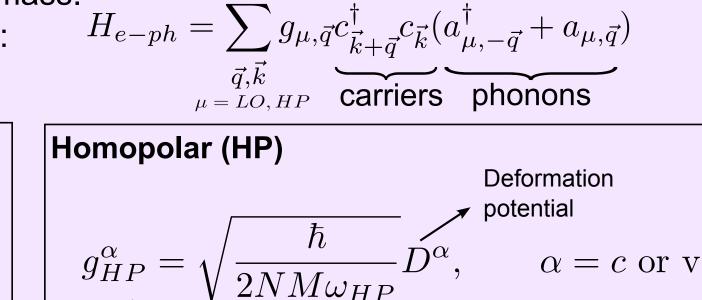
Photo-excited carriers at the K/K' valleys, relax inelastically by emitting phonons, allowing them to reach the bottom of the conduction (c) and valence (v) bands where they can then radiatively recombine. We predict ps-scale relaxation of photo-excited carriers in TMDCs, which is mediated by the emission of longitudinal optical (LO), and homopolar (HP) phonons. We evaluate the Born effective charges for MoS₂, MoSe₂, WS₂, and WSe₂, and the corresponding LO phonon couplings, to calculate the cooling times for hot electrons and holes from excitation energies of several hundred meV.



Sketch of the relaxation process at the K/K'-valleys.

Phonon mediated relaxation in TMDCs

- We analyse the phonon mediated cooling of hot carriers in TMDCs, focusing on two optical phonon modes coupled to the intra-valley relaxation process: the in-plane longitudinal optical (LO), and the out of plane homopolar (HP) phonon modes, with a constant energy dispersion.
- These are the only two modes coupled to the intra-valley relaxation process, and having a finite coupling at the Γ -point, as dictated by the point group symmetry of the crystal, D_{3h}.
- Density functional theory calculations show a sufficiently large energy gap between the K and Q vallyes [3] (particularly for Mo based TMDCs), and weak carrier coupling with K-point phonons, allowing to focus only on the intra-valley scattering.
- At the K/K'-points, for energies up to 0.25 eV, the carriers can be approximated as having a parabolic energy dispersion with an effective mass.
- The carrier-phonon interaction Hamiltonian:



Unit cell

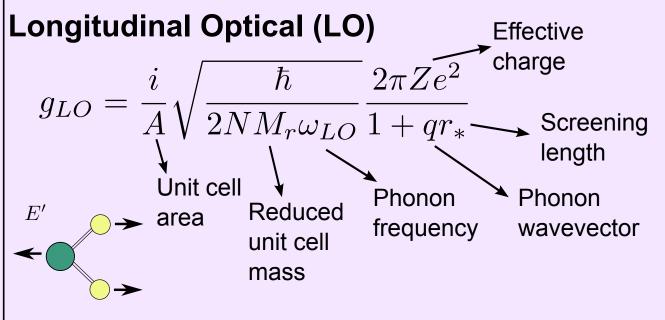
2.3

Phonon

3.1

-1.08

frequency



 $\frac{m_c}{m_0} [3] \quad \frac{m_v}{m_0} [3] \quad A [3]$

0.54

0.59

0.36

 MoS_2

 $MoSe_2$

 WS_2

 WSe_2

0.46

0.56

0.26

0.28

					\					
TMDCs parameters used in the modelling of phonon emission rates										
$\frac{v}{0}$ [3]	A[3]	$\frac{M_r}{m_p}$	$\frac{M}{m_p}$	$\hbar\omega_{LO}$ [4]	$\hbar\omega_{HP}$ [4]	D_c [4]	D_v [4]	Z	$r_{*} [5]$	
J	$[\mathring{\rm A}^2]$	P	P	$[\mathrm{meV}]$	[meV]	$[{ m eV/\AA}]$	$[{ m eV/\AA}]$		$[m \AA]$	
).54	8.65	38.4	160	49	51	5.8	4.6	-1.08	41	
0.59	9.37	59.7	254	37	30	5.2	4.9	-1.80	52	
0.35	8.65	47.5	248	44	52	3.1	2.3	-0.47	38	

LO phonon coupling in 2D TMDCs

85.0

342

8.65

9.37

The LO mode couples to charge carriers through the polarization $\vec{P}_{op} = \frac{Ze}{\Lambda}\vec{u}$, which is induced by the lattice deformation given by the relative displacement $ec{u}$, and the opposite effective charge on the two sublattices, given by the Born effective charge tensor,

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$$Z_{ij} = \frac{1}{e} \left. \frac{\partial F_j(s)}{\partial E_i} \right|_{E=0} \qquad \text{Partial derivative of the j}^{\text{th}} \text{ component of the force on atom s} \\ \text{at zero-field equilibrium position, with respect to i}^{\text{th}} \text{ component of the force on atom s} \\ \text{of the electric field.}$$

31

In 2D, unlike 3D, the resulting coupling has a finite value at the Γ -point, with a momentum dependent dielectric function. The coupling is obtained from the electrostatic interaction energy in 2D [6],

$$E_{int} = \frac{1}{2} \int \frac{d^2r d^2r'}{|r-r'|} \sigma(r) \sigma(r') + \underbrace{\frac{1}{2\kappa}}_{\text{in-plane rigidity}} \int d^2r (P_{\perp}^2 + P_{op}^2), \quad \sigma(r) = \underbrace{e\rho(r) - \nabla \cdot \vec{P}_{op}}_{\text{2D charge optical phonon other in-plane density}}_{\text{polarization}} - \underbrace{\nabla \cdot \vec{P}_{op}}_{\text{2D charge optical phonon other in-plane polarization}}_{\text{polarization}}$$

In the static approximation, integrating out the in-plane polarization $ec{P}_{\perp}$, and Fourier transforming the integrand, we obtain the carrier-phonon interaction energy term composed of the phonon induced polarization and carrier density, from which we obtain the coupling coefficient,

 $E_{e-ph} = \int \frac{d^2 \vec{q}}{(2\pi)^2} \frac{2\pi i e \hat{q} \cdot \vec{P}_{op,\vec{q}} \rho_q^*}{1 + 2\pi \kappa q}$

References

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Phonon emission rates

The emission rates are calculated using the $au^{-1}=rac{2\pi}{\hbar}\sum_{\vec{j}}|\langle f|H_{e-ph}|i\rangle|^2\delta(E_f-E_i).$ Fermi golden rule:

The phonon emission rates are valid only for carrier energies larger than the corresponding phonon energy.

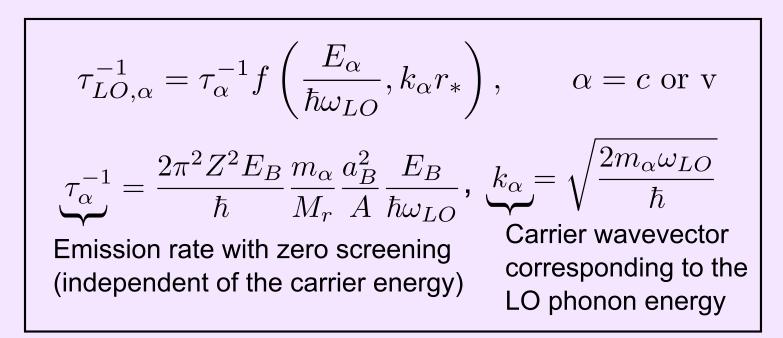
HP phonon

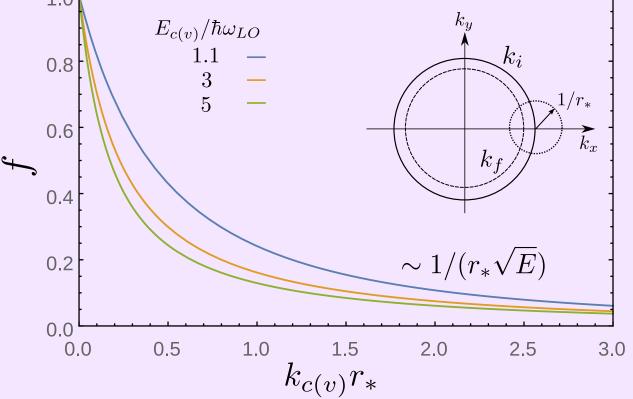
The HP phonon emission rate is a constant independent of the carrier energy:

$$\tau_{HP,\alpha}^{-1} = \frac{m_{\alpha} A D_{\alpha}^{2}}{2M\hbar^{2}\omega_{HP}}, \quad \alpha = c \text{ or v}$$

LO phonon

The LO phonon emission rate has dependance on both the carrier energy and the screening length. The screening length limits the dominantley contributing phonon wavevectors ($q \leq 1/r_*$) to the scattering process:





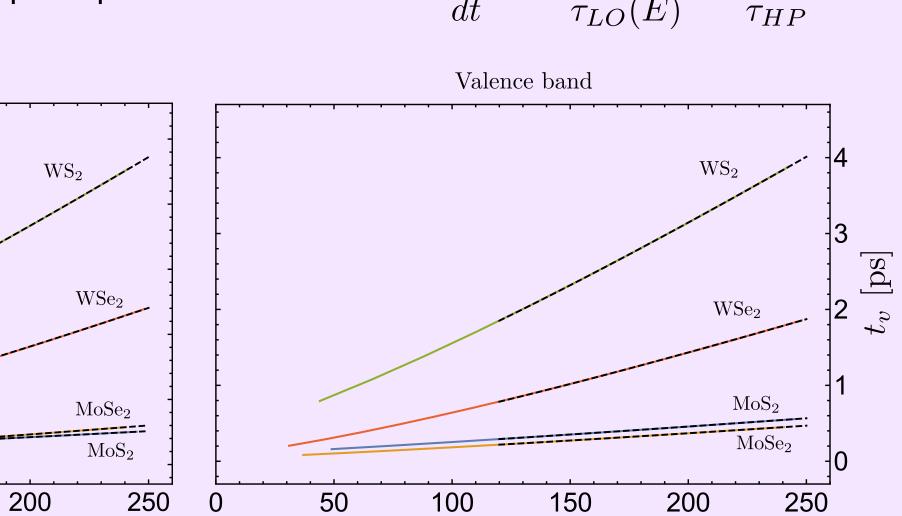
 $\hbar\omega_{HP}$

Relaxation times

 $\begin{bmatrix} Sd \end{bmatrix}$ 3

The energy relaxation rate due to optical phonons emission:

Conduction band



E [meV]

E [meV]Relaxation times for electrons (left) and holes (right) as a function of the initial carrier energy.

Asymptotic form of the relaxation time (dashed) for large carrier energies $(E \gg \hbar\omega_{LO}, \hbar\omega_{HP})$:

150

$$t(E) \approx aE - b\sqrt{E} + c$$

Values of derived and fitted parameters WSe_2 MoS_2 $MoSe_2$ WS_2 $k_c \, [\text{\AA}^{-1}]$ 0.0770.0740.0550.0480.0830.0760.0640.054296 45 $\tau_v^{-1} [\text{ps}^{-1}]$ 31258 $\tau_{HP,c}^{-1}[ps^{-1}]$ 0.54 $\tau_{HP,v}^{-1}[\mathrm{ps}^{-1}]$ 5.01.3 $a_c \left[\frac{\mathrm{ps}}{\mathrm{meV}} \right]$ $3.9 \cdot 10^{-3}$ $2.3 \cdot 10^{-3}$ 0.0290.0170.170.0120.0330.140.150.70 $c_c [ps]$ $2.7 \cdot 10^{-3}$ $2.6 \cdot 10^{-3}$ 0.0230.0120.0170.0180.180.10 $c_v [ps]$ 0.150.101.03 0.45

Summary

- The relaxation times of photo-excited carriers in 2D TMDCs due to emission of optical phonons, are of a few ps for all the materials studied.
- MoSe₂ and MoS₂ have the shortest sub-ps relaxation times for all carrier energies up to ~0.25 eV, which is attributed to their respective unit cell Born charges, and optical deformation potentials.
- ullet The 2D LO phonon coupling has a finite value at the Γ -point, and a decreasing scattering rate with increasing carrier energy due to the lattice screening.
- The LO phonon typically dominates over the HP phonon mode, however for larger screening lengths and high carrier energies the two become comparable.
- The relaxation times obtained for WS₂ and WSe₂ are a lower bound, due to the energy allowed K→Q intervalley scattering in these materials.

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